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🔍 Title: **DD0215706A1: VERFAHREN UND VORRICHTUNG ZUM REINIGEN V GASEN UND DAEMPFFEN AUS PLASMAANLAGEN**

🔍 Derwent Title: Plasma waste gases cleaning - by passing across plasma between reactant plate and vacuum container walls [\[Derwent Record\]](#)

🔍 Country: **DD** German Democratic Republic

🔍 Kind: **A1** Prov. Economic Patent ⁱ

🔍 Inventor: **RAENSCH, CHRISTIAN ,DD**; German Democratic Republic

🔍 Assignee: **VEB ZFT MIKROELEKTRONIK ,DD** German Democratic Republic
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🔍 Published / Filed: **1984-11-21 / 1983-05-30**

🔍 Application **DD1983000251388**

Number:

🔍 IPC Code: Advanced: **B01D 53/34**;

Core: more...

IPC-7: **B01D 53/34**;

🔍 ECLA Code: None

🔍 Priority Number: 1983-05-30 **DD1983000251388**

🔍 INPADOC
Legal Status:

Gazette date	Code	Description (remarks) <small>List all possible codes for DD</small>
1994-01-27	PV -	Patent disclaimer (addendum to changes before extension act)

🔍 Family:

Buy PDF	Publication	Pub. Date	Filed	Title
<input checked="" type="checkbox"/>	DD0215706A1	1984-11-21	1983-05-30	VERFAHREN UND VORRICHTUNG ZUM REINIGEN VON GASEN UND DAEMPFE PLASMAANLAGEN
1 family members shown above				

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References:

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Buy PDF	Patent	Pub. Date	Inventor	Assignee	Title
<input checked="" type="checkbox"/>	US6998027	2006-02-14	Chiu; Kin-Chung Ray	DryScrub, ETC	Highly efficient compact capacitive coupled plasma reactor/generation method

Other Abstract Info: None



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